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Current-Voltage Characteristic of Bridgeman-Stockbarger InGaSe₂ thin films

3 ABSTRACT

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5 The monocrystals $InGaSe_2$ were grown by Bridgeman-Stockbarger **method**. The 6 current-voltage characteristic was studied in the rectangular form samples of sizes $7x1x1mm^3$. 7 In and Cu served as contacts. The current supplying the ends of rectangular samples is

oriented so that the current flows through the sample along the axis c of the monocrystal 8 InGaSe₂. The current-voltage characteristic was investigated on direct current in static mode. 9 10 Investigations of luminescence properties of the compound InGaSe₂ were carried out by means of spectrofluormeter Cary Eslipse, the production of the firm Varian. Statistical current-voltage 11 12 characteristic of InGaSe₂ at different temperatures, temperature change of samples in the 13 domain of negative incremental resistance, dependence of threshold voltage on temperature 14 were studied. It was revealed that the given phase possesses switching properties, with 15 memory and with decreasing the temperature, the value of the threshold voltage increases, and 16 as a result, the S-shaped characteristic becomes strongly-pronounced. Change of the 17 threshold voltage due to temperature change was analyzed. The spectrum of fluorescence of the compound InGaSe₂ in the interval of wavelength 300-600nm was studied, and it was 18 19 revealed that given material is widely used in multifunctional electronic devices.

Keywords: switching, X-ray analysis, thin films, S-shaped characteristic, threshold voltage,
chain structure, fluorescence spectrum, InGaSe₂ compounds.

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1. INTRODUCTION

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In [1] the ternary compounds A^{III}B^{III}C₂^{VI} were intensively studied. These compounds have 25 not lost their urgency up today owing to their unique physical properties and practical 26 application. The above-mentioned compounds and their triple analogues A^{III}B^{III}C₂^{VI} belong to 27 the group of chain-layered crystals [1-3]. These compounds occupy a special place among high 28 29 anisotropy crystal structure compounds. In references, there exist many papers devoted to 30 structural, physical-chemical, electro-physical, photoelectrical and other properties of triple compounds as A^{III}B^{III}C₂^{VI} [4-6]. In particular, along with investigations of physical properties, the 31 energy-band structures, optic functions were calculated effective mass of electrons and holes 32 33 were determined and by the researchers of current-voltage characteristics of compounds as $A^{III}B^{III}C_2^{VI}$ it was revealed that these compounds possess switching properties with memory[7]. 34 35 In references there are numerous works development to current-voltage characteristics (currentvoltage characteristic) of semiconductor compounds and solid solutions of above mentioned 36 37 type, and also to search of new materials with more qualitative phylisical parameters [8,9]. There 38 are also some informations on investigation of triple compound InGaSe₂, in particular, electro-39 physical, thermo-physical properties were investigated, the energy-band structure and optic 40 functions were calculated. But the properties including current-voltage characteristic of the 41 compound InGaSe₂ were not studied enough.

Furthermore, for studying the properties of these samples, influencing on measurable parameters, the highly sensitive fluorescence method is used. The luminescence spectra of semi-conductors give valuable information of energy-band structure and electron properties. They are widely used in investigation of optic properties of semi-conducting nanoparticles. The goal of the paper is to study the current-voltagecharacteristics and spectra of fluorescence of the compound InGaSe₂.

2. METHODS OF CALCULATION

For the synthesis of $InGaSe_2$ the elements with the following purity were used: In – especially pure, Ga – 99,996 and Se – SP(ultrapure). The ampoules were cleaned by mixture HF with distilled water. After chemical cleaning the ampoules evacuated to 0,0133 Pa were located into a furnace at 1000°C for 24 hours then cooled to room temperature and were filled with highly cleaned elements. For synthesis of InGaSe₂ in order to decrease the explosion risky, the amploues the mixture was slowly (with velocity 0,5 deg/min) heated from room temperature to 200°C. Then temperature was increased te 950°C and for homogenization of the alloy it was hold at this temperature during 48 hours. Then the crucible was slowly with velocity 0.6 mm/hour cooled by moving from warm zone to cold one at 350°C, was hold during 8 hours and cooled to room temperature at temperature 970°C.

The current-voltage characteristics of InGaSe₂ was studied on rectangular form samples of size 7x1x1mm³. In and Cu served as contacts. The contacts were verified by four-point method, by sequential measurement of resistance in samples. The current supplying the ends of rectangular samples is directed so that the current through the sample flows along the

axis c of the monocrystal current-voltage characteristic were investigated in direct current according to standard technique described in [11].

Investigations of luminescent properties of the compound InGaSe₂ were carried out by means of spectrofluorimeter Cary Eclipse the production of the firm Varian. Principal device and working elements of the device are given in the scheme (fig.1)



Fig. 1. Scheme the device spectrofluorimeter: 1 - source; 2 - lenses; 3 -excitation monochromator; 4 - ditch to place the sample; 5 - monochromator for emitting light; 6 - photomultiplier; 7 - recording device

As a radiation source used a xenon lamp working in impulse condition with width of impulse 2 mcs and power 75 kWatt. Both monochromotors possess high velocity scanning abilities. It means that 3 sec. suffices for defnition of total spectrum. By means of spectrofluorimeter Cary Eclipse af the range of wavelength 200-900 nm one can observe the fluorescence and phosphorescence phenomena. Changing the width of transmission slot from 1,5 to 20 nm one can manage the intensity of the signal going in optic system. The measurements are conducted in automated condition. Auxiliary programs admit to choose various measurement conditions

and to control working elements.

3. RESULTS AND DISCUSSION

 101 With increasing the voltage I(U) the characteristic damped and was strictly nonlinear 102 and of S-shaped form it was revealed that in ohmic area, temperature remains constant, and in 103 the area of negative differential drag increases to temperature T, usually greater than ambient 104 temperature.

105 The current-voltage characteristic of InGaSe₂ was studied af different temperatures at 106 the temperature range 80-300 K (fig.2). As it follows, at lower voltages I(U) dependen is linear 107 and the contact is ohmic. 108



147 The experiment showed that the samples temperature is higher than ambient 148 temperature. Dependece of threshold voltage on sample's temperature was shown in fig.4.

Analysis of the obtained results shows that the area controlled by current is corrected with increasing the sample's temperature. According to the obtained data(fig.2), there happens migration of threshold voltage to higher values with decreasing ambient temperature and weak appearance of the area of negative differential drag on current-voltage characteristic because of ambient temperature increase.

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Fig. 3. The current-voltage characteristic of $InGaSe_2$ (chart showing temperature changes in the negative area)

Note that the OC on current-voltage characteristic diode on the basis of InGaSe₂ may by formed only in availability of internal positive feedback. For a diode with S-shaped current-voltagecharacteristic, positive feedback in current is formed. Uth, V 350 T, K Fig. 4. The dependence of the threshold voltage of the temperature for InGaSe₂ This means that any change of current should cause its further change in the same direction. Analyze the conditions of appearance of negative differential drag in InGaSe₂ with p-n passage junction. Such a diode way by represented in the form of sequentially switched electrone-hole junction and drag of highohmic basic area of the samples. In this case, the voltage U applied to the diode on the basis of the compound InGaSe₂ consists of voltage drop on p-n junction U_0 and on the thickness of the base U_T : $U=U_0+U_T$ (1) Moreover $U_{\rm T} = IR_{\rm T} = \frac{I}{\sigma_{\rm T}}; U_0 = \left(\frac{\beta kT}{q}\right) \ln\left(\frac{I}{I_0} + 1\right);$ where I_0 is a pre-exponential factor; β is a coefficient accepting the values between 1 and 2

where I_0 is a pre-exponential factor; β is a coefficient accepting the values between 1 and 2 depending on parameters of p-n junction and flowing current, R_T and σ_T is drag and conductance of the thickness of the base of the diode: $\sigma_T = \sigma_0 + \sigma^*$ (σ_0 is the conductance of the base in the absence of injection, σ^* is additional conductance stipulated by injection and growing by increasing the current through the sample). In the case when the material is homogeneous and doesn't contain the trapping cite, concentration of injected carriers of current linearly increase with increasing the current through the p-n junction. In availability of traps or in homogeneities the conductance in basic area, with change of the flowing current will change not by linear but by more complicated law that may be expressed in the form

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$$\sigma_T = \sigma_0 \left[1 + \left(\frac{I}{I_1} \right)^{\gamma} \right],$$

200 Where I_1 is a constant value expressed by electro physical parameters of the base material. In 201 this case, expression (1) takes the form

$$U = \frac{Id}{\sigma_0 \left[1 + \left(\frac{I}{I_1}\right)^{\gamma}\right]} + \frac{\beta kT}{q} \ln\left(\frac{I}{I_0} + 1\right).$$
(2)

By differentiating equation (2), we find differential drag of the direct branch of the considered diode:

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$$\frac{dU}{dI} = \frac{1 + \left(\frac{I}{I_1}\right)^{\gamma} (1 - \gamma)}{\sigma_0 \left[1 + \left(\frac{I}{I_1}\right)^{\gamma}\right]^2} d + \frac{\beta kT}{q(I + I_0)}.$$

206 When passing from the positive differential drag to negative one, $\frac{dU}{dI} = 0$. Therefore, the

207 condition of existence of the negative drag may be written in the form

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$$1 + \left(\frac{I}{I_1}\right)^{\gamma} (1 - \gamma) + \frac{\beta kT}{qd} \frac{\sigma_0 \left\lfloor (1 + I/I_0)^{\gamma} \right\rfloor}{I + I_0} = 0.$$

This condition may be fulfilled only for $\gamma > 1$. At linear or weaker dependence of the conductance of the base through p-n junction, i.e. for $\gamma \le 1$, the area OC on current- voltage characteristic is absent. Thus, it is seen from the cited example that change of conductance of the base only at the expense of injection doesn't reduce appearance of OC area on current- voltage characteristic of the diode. There should exist one more reason of change of conductance.

At small voltages, the drag of the base is great and almost all applied voltage drop on a 214 215 diode. With increasing voltage, the injected carrier's concentration in the base increases and its drag drops. However, for v≤1, R_T decreases no faster than drag of p-n junction. Therefore, with 216 217 increasing current the voltage field increases. The current is a monotone function of the applied 218 voltage. If v>1, the conductance of the thickness increases faster than conductance of p-n 219 junction. This reduces to decrease in the proportion of the voltage drop on the base and this 220 reduces to strengthening and new redistribution of voltage between the base and p-n junction. 221 This is a positive feedback necessary for appearance of negative drag. Thus existence of 222 additional base area accompanying the injection of mechanism of increasing of conductance is 223 the necessary condition for emergence of negative drag in InGaSe₂. For understanding the 224 nature of negative drag, it is necessary to consider namely these physical phenomena 225 additional to injection.

Current-voltage characteristic with long base (d>>L) and at the coefficient of injection of p-n junction equal to a unit may be approximately represented by the expression [10]:

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$$I = \frac{kTch(d/L)}{2q\rho_0 L(b+1)} (e^{qU/ckT} - 1)$$

where, *L* is the length of diffusive shift at higher levels of injection; ρ_0 is the resistivity; *b* is the ratio mobility of electrodes and holes; *d* is the thickness of the base area:

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The constant *c* exponentially increases with increasing the ratio d/L. Therefore, total current very strongly depends on this ratio. If with increasing the level, the lifetime increases, this reduces to sharp increase in current. The carrier density on the base increases avalanche.

C=2(b+chd/L)/(b+1).

Injection of not the main carriers by p-n junction increases their lifetime in volume. For this reason the further reduction of the base drag that reduces to redistribution of voltage between the base and p-n junction happens. The share of voltage in p-n junction increases. As a result, there happens additional injection of carriers of current, further increase of lifetime etc. Such a process reduces to emergence of OC on current- voltage characteristic of the compound InGaSe₂.

In conclusion, it should be noted that the three-fold compound InGaSe₂ possessing switching properties with memory and its S-shaped current-voltage characteristic may be successfully used in creation of sensitive switches.

The results obtained from investigation of current-voltage characteristics of compound InGaSe₂ is good consistent with [9,13].

The typical feature of the spectrum of fluorescence (CF) is high resolving ability accompanied 246 by the processes connected with chemical structure of the sample, of the elements of the 247 248 structure and other dynamic changes SF possesses rather short time range as after 10⁸sec. 249 After light absorption, fluorescence begins. During this period of time all the processes on 250 molecular level, nonradioactive energy transfers and exchange of charges and energies 251 between the components find their reflection in spectra of fluorescence. Therefore SF are very convenient when observing the results of short dynamic processes, by studying statically 252 253 composition and properties of the structure and also the processes that are revealed by means of light signal. The narrow stripes of luminescence found in the visible area depend on the sizes 254 of semiconductor nanoparticles, and analyzing this dependence one can determine the 255 256 influence (or effect) of the sizes of nanoparticles on optic and electric properties of 257 nanocomposites.



Fig. 5. The fluorescence spectrum of InGaSe₂

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The results of investigations of the spectrum of fluorescence is represented in fig.5. The excitation spectrum of InGaSe₂ at wavelength 247.03 nm was shown. The spectra were recorded at the width of the slot 2.5 nm. As is seen, at wavelength 322.00; 415.97; 498.95 nm we observe the peaks of excitation spectra for InGaSe₂. The greatest peak holds at the excitation signal with wavelength 498.95 nm. Intensity of the peak inherent to the wavelength 498.95 nm is much more than intensity of peaks af 322 and 415.87 nm.

Thus, two studied the spectra of fluorescence of the compound InGaSe₂ at the range of wavelength 300-600 nm, revealed that the given material may be widely used in multifunctional electronic devices[12].

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4. Conclusion 286

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288 Investigations of current-voltage characteristics of the three-fold compound InGaSe₂ in 289 static mode showed that this compound possesses switching properties with memory.

290 Experimental current-voltage characteristics of the compound InGaSe₂ are linear at lower, 291 and nonlinear at higher current densities. The nonlinear mode (ODC - areas) has S-shaped 292 form. Stable state of current- voltage characteristic and peculiarities of their ODC area way be interpreted by electronic – thermal mechanism. It was revealed that increase of heating of the 293 294 inner part of the sample reduces to increase in high concentration of free carriers in this area because of semi-conductor character of InGaSe₂ and reduction of the value of the threshold 295 296 voltage. With changing ambient temperature, the sizes of ohmic contact and from InGaSe₂ one 297 can obtain switches with required physical parameters. The spectrum of fluorescence of the compound InGaSe₂ was studied, and it was revealed that the present phase possesses 298 299 luminescence properties at wavelength 498.95 nm and may be widely used in multifunctional electronic devices. The results of fluorescent effect that found in InGaSe₂ compound is good 300 301 consistent with the work[14].

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REFERENCE 303

- 1. Tap H., Weltman brothers ternary chalcogenides of potassium with gallium and indium. 304 Science, 1967; 54 (2): 42-48. 305
- 306 2. Müller D., Eulenberger G. und Hahn H. Über ternare Thalliumchalkogenide mit thalliumsselennid-structur. Z. anorg. allg. chem.1973; 398(2):207-220 . 307
- 308 3. Mooser E., Pearson W.B. The chemical bond in semiconductors. J. Electronics. 309 1956;1(6):629-645.
- 4. Gojayev E.M., Jafarov H.S., Safarova S.I. TIInTe2 band structure and thermal efficiency 310 of solid solutions based on it // Thermoelectricity. 2013; 1: 28-33. 311
- 312 5. Gojayev E.M., Aliyeva P.F., Rahimov R.S., Abdurahmanova U.S., Ismailov A.A. Calculation of band structure and optical functions ternary compounds InGaSe2, 313 InGaTe2. Proceedings of the VIII International Symposium. Fundamental and applied 314 problems of science. Moscow, 2013; I: 59-67. 315
- 6. Godzhayev E.M., Orudzhev G.S., Kafarova D.M. Band structure and dielectric 316 permeability of compound $TlGaTe_2$. Physics of the solid state, 2004;46(5): 833-835. 317
- 7. Godzhayev E.M., Orudzhev G.S., Kerimova R.A., Allakhyarov E.A. Band structure and 318 optical properties of chained compound TIInTe₂., Phys. Stat. sol. 2006; 48: 40-43. 319
- 320 8. Godzhayev E.M., Pashayev A.M., Movsumov A.A., Halilova H.S., Agayeva S.H. Akustofotovoltaic effects in TIIn_{0.98}Cd_{0.02}Se₂ monocrystals Inorganic materials 321 2010;46(1):20-23. 322
- 9. Hanias M., Anagnostopoulos A.N., Kambas K., Spyridelis J. I-U dependence of TIInX₂ 323 (X=Se, Te) single crystals: The Ohmic and S-type regions Physical RewiewB, 324 325 1991;43(5):4135-4140
- 326 10. Mailov A.A. Switching devices based on amorphous semiconductor materials. -"Electronic Equipment", a series U1 "Microelectronics", 1971; 3: 3-13. 327

328	11. Gojayev E.M., Gulmammadov K.C., Khalilova Kh.S., Guliyeva S.O. Switching effect in
329	thin films of TIInSe2. Electronic materials processing, 2011; 47 (5): 18-22.
330	
331	12. Kazim-zade A.G., Salmanov V.M., Salmanov A.A., Aliev A.M., Ibayev R.H.
332	Photoconductivity and luminescence of crystals GaSe at high levels of optical excitation.
333	FTP, 2010; 44 (3): 306-309.
334	13. R.H. Al Orainy, Interpretation of Switching Properties of InGaSe ₂ Single Crystal. Acta
335	Physica Polonica A Vol. 2012; 121 (3): 666-672.
336	
337	14. E.M.Godzhayev, N.S.Nabiev, Sh.A.Zeinalov, S.S.Osmanova, E.A.Allakhyarov and
338	A.G.Gasanova. A Study of the Fluorescence Spectra and Dielectric Properties of HDPE
339	+ x vol% TIGaSe2 Composites, Surface Engineering and Applied Electrochemistry, 2013,
340	vol.49,No3, pp.194-198
341	
342	